

FORM PTO-1449
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 INFORMATION DISCLOSURE
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YEUNG et al

 FILING DATE
October 30, 2000

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1711

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OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

C.I.P.E.O. 52	S. Creutz, P. Teyssie, R. Jerome, <u>Living Anionic Homopolymerization and Block Copolymerization of (Dimethylamino)ethyl Methacrylate</u> , <u>Macromolecules</u> , 30, pg. 6-9 (1997)
NOV 1 6 2001 PATENT & TRADEMARK OFFICE	P. Chaumont, D. Colombani, L. Boiteau, J.P. Lamps, M. Zink, C.P.R. Nair, and P. Charmot, <u>Free Radical Synthesis of Functional Polymers Involving Addition-Fragmentation Reactions</u> , American Chemical Society (Chapter 22, pg. 362-376) (1998)
O.A.	J. Chiefari, Y. K. Chong, F. Ercole, J. Krstina, J. Jeffrey, T. Le, R. Mayadunne, G. Meijs, C. Moad, G. Moad, E. Rizzardo, S. Thang, <u>Living Free-Radical Polymerization by Reversible Addition-Fragmentation Chain Transfer: The RAFT Process</u> , <u>Macromolecules</u> , 31, pg. 5559-5562 (1998)
O.A.	A. Sebenik, <u>Living Free-Radical Block Copolymerization Using Nitro-Iniferters</u> , <u>Prog. Polym. Sci.</u> Vol. 23, pg 875-917 (1998)
O.A.	J. Krstina, C. Moad, G. Moad, E. Rizzardo, <u>A New Form of Controlled Growth Free Radical Polymerization</u> <u>Macromol. Symp.</u> 111, pg. 13-23 (1996)
O.A.	S. Sandler, W. Karo, <u>Organic Chemistry, Polymer Syntheses Vol. II</u> , Academic Press N.Y., Chapter 7, <u>Poly(Vinyl Ethers)</u> , pgs. 214-231 (1974)
O.A.	V. Butun, N. Billingham, S. Armes, <u>Synthesis and Aqueous Solution Properties of Novel Hydrophilic-Hydrophilic Block Copolymers Based on Tertiary Amine Methacrylates</u> , <u>Chem. Commun.</u> 671-672 (1997)
O.A.	S. Creutz, J. van Stam, F. De Schryver, R. Jerome, <u>Dynamics of Poly((dimethylamino)alkyl methacrylate-block-sodium Methacrylate) Micelles. Influence of hydrophobicity and Molecular Architecture on the Exchange Rate of Copolymer Molecules</u> , <u>Macromolecules</u> , 31, 681-689 (1998)
O.A.	A. Lowe, N. Billingham, S. Armes, <u>Synthesis and Characterization of Zwitterionic Block Polymers</u> , <u>Macromolecules</u> , 31, 5991-5998 (1998)
O.A.	D. Shipp, J.L. Wang, K. Matyjaszewski, <u>Synthesis of Acrylate and Methacrylate Block CoPolymers Using Atom Transfer Radical Polymerization</u> , <u>Macromolecules</u> , 31, 8005-8008 (1998)
O.A.	X. Zhang, K. Matyjaszewski, <u>Synthesis of Well Defined Amphiphilic Block Copolymers with 2 Dimethylaminoethyl Methacrylate by Controlled Radical Polymerization</u> , <u>Macromolecules</u> 32, 1763-1766 (1999)
O.A.	N. Hoogeveen, M. Sohen Stuart, G. Fleer, <u>Novel Water-Soluble Block CoPolymers of Dimethylaminoethyl Methacrylate and Dihydroxypropyl Methacrylate</u> , <u>Macromolecules Chem. Phys.</u> , 197, pg. 2553-2564 (1996)

EXAMINER

Olga Asinowsky

DATE CONSIDERED

June 19, 2002

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EXAMINER INITIAL	DOCUMENT NUMBER							DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
OIA NOV 16 2001 PATENT & TRADEMARK OFFICE	4	5	2	8	1	1	1	07/85	Su			
	5	3	3	8	5	4	1	08/94	Matz et al			

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER							DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
												YES	NO
O.A.	9	8	0	1	4	7	8	01/98	WO			X	
C.A.	5	3	1	1	1	9	4A2	11/93	JP			Abstract and Computer	

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